

U.S.S.N. 10,811,621

Claim Amendments

Please amend claims 1-17 as follows:

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**Listing of Claims**

1. (currently amended) An electrolyte bath ~~comprising a suspension layer for forming a wetting layer on a substrate for copper electroplating~~, comprising:

an electrolyte solution suitable for metal electroplating; and

a composition comprising an organic acid and a non-ionic polymer mixed with said organic acid ~~provided in said electrolyte solution~~;

wherein said composition ~~forms~~ is disposed as a separated suspension layer within said electrolyte solution, said suspension layer of sufficient dimension to form a wetting layer on a substrate as said substrate is passed through said suspension layer.

2. (currently amended) The electrolyte bath of claim 1 wherein said organic acid is citric acid or acetic acid.

3. (currently amended) The electrolyte bath of claim 1 wherein said non-ionic polymer is an alcohol, an amine or alkylphenol

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alkoxylate.

4. (currently amended) The electrolyte bath of claim 1 wherein said composition is present in said electrolyte solution in a concentration of about 5 % by weight.

5. (currently amended) The electrolyte bath of claim 1 wherein said non-ionic polymer has a molecular weight of less than 1,000.

6. (currently amended) The electrolyte bath of claim 5 wherein said organic acid is citric acid or acetic acid.

7. (currently amended) The electrolyte bath of claim 1 wherein said organic acid is present in said composition in a wt.% of about 10, and wherein said non-ionic polymer is present in said composition in a wt.% of about 5.

8. (currently amended) The electrolyte bath of claim 7 wherein said organic acid is citric acid or acetic acid and said non-ionic polymer is an alcohol, an amine or alkylphenol alkoxylate.

9. (currently amended) An electrolyte bath ~~comprising a suspension layer for forming a wetting layer on substrate prior to copper electroplating said substrate layer within said~~

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electrolyte, comprising:

an electrolyte solution suitable for copper electroplating; and

a second composition comprising an organic acid and a non-ionic polymer mixed with said organic acid;

wherein said composition ~~forms~~ is disposed as a separated suspension layer within said electrolyte solution, said suspension layer ~~for forming~~ of sufficient dimension to form a wetting layer on a substrate as said substrate is passed through said suspension layer.

10. (currently amended) The electrolyte bath of claim 9 wherein said organic acid is citric acid or acetic acid.

11. (currently amended) The electrolyte bath of claim 9 wherein said non-ionic polymer is an alcohol, an amine or alkylphenol alkoxylate.

12. (currently amended) The electrolyte bath of claim 11 wherein said composition is present in said electrolyte solution in a concentration of about 5% by weight.

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13. (currently amended) The electrolyte bath of claim 9 wherein said organic acid is present in said composition in a wt.% of about 10, and wherein said non-ionic polymer is present in said composition in a wt.% of about 5.

14. (currently amended) The electrolyte bath of claim 13 wherein said organic acid is citric acid or acetic acid.

15. (currently amended) The electrolyte bath of claim 13 wherein said non-ionic polymer is an alcohol, an amine or alkylphenol alkoxylate.

16. (currently amended) The electrolyte bath of claim 15 wherein said organic acid is citric acid or acetic acid.

17. (currently amended) A method for electroplating a metal onto a surface in an electroplating electrolyte solution, comprising the steps of:

providing a composition mixture comprising an organic acid and a non-ionic polymer;

forming a suspension layer of said composition mixture

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within said electrolyte solution;

forming a wetting layer on said surface by passing said surface through said suspension layer and into said electrolyte solution; and

electroplating said metal onto said surface following forming said wetting layer.

18. (previously presented) The method of claim 17 wherein said organic acid is citric acid or acetic acid and said non-ionic polymer is an alcohol, an amine or alkylphenol alkoxylate.

19. (previously presented) The method of claim 17 wherein said organic acid is present in said composition in a wt.% of about 10, and wherein said non-ionic polymer is present in said composition in a wt.% of about 5.

20. (original) The method of claim 17 further comprising a substrate and wherein said surface comprises a metal seed layer deposited on said substrate.